

# Low Temperature MBE Growth and Characterization of (111) $\text{Sn}_{1-x}\text{Mn}_x\text{Te}$ Thin Epitaxial Layers

## Obtained with Additional Te Flux

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## Introduction / Motivation

### Topological crystalline insulators:

→ SnTe is an archetypical topological crystalline insulator

**Material: Ternary  $\text{Sn}_{1-x}\text{Mn}_x\text{Te}$ :**

→ Transition metal Mn-doped SnTe is a ferromagnet

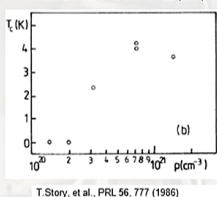
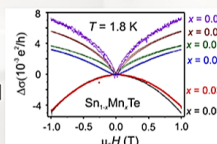
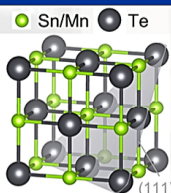
→ RKKY exchange interaction

### Motivation

→ Predicted coexistence of topological insulator, magnetism, and ferroelectricity. Combined with superconductor can be useful in superconductor spintronics.

### Goal of present work

→ Growth of thin (111)  $\text{Sn}_{1-x}\text{Mn}_x\text{Te}$  epilayers by MBE. Study how Te excess affects structure and magnetic properties of the epilayers.

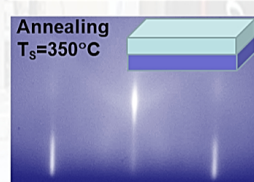
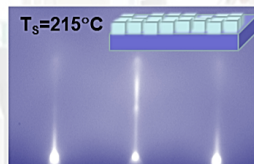


### MBE growth

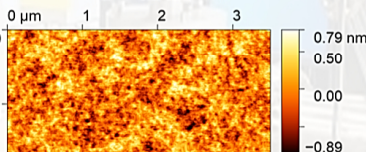
- Veeco GENxplor, SnTe, Mn, Te sources
- (111)  $\text{BaF}_2$  substrates
- The initial layer with rough surface was formed by the rapid coalescence of Volmer-Weber islands to minimize elastic strains
- Subsequent rapid annealing step at a higher temperature was used to minimize the film surface energy
- *in-situ* RHEED revealed evolution of pattern due to surface smoothing
- AFM confirms atomically smooth surface (RMS roughness  $\sim 275$  pm)
- XRD, only (111) orientation, no strains detected from asymmetric RSM

## Two step growth

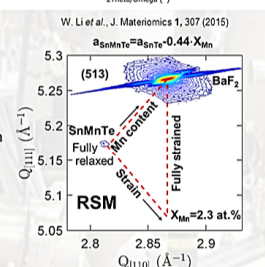
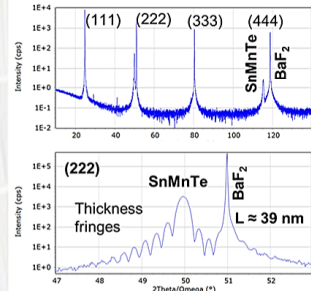
### RHEED [112]



### AFM



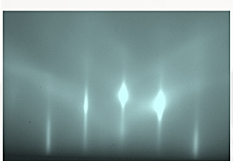
### XRD



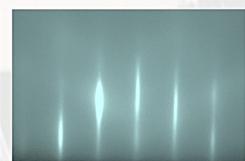
## Te flux influence

### Te low

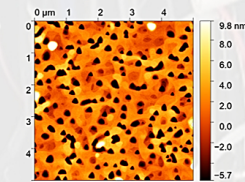
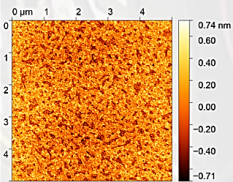
### RHEED



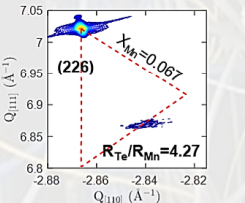
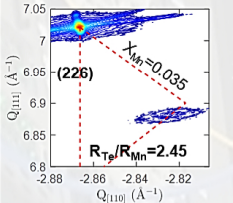
### Te high



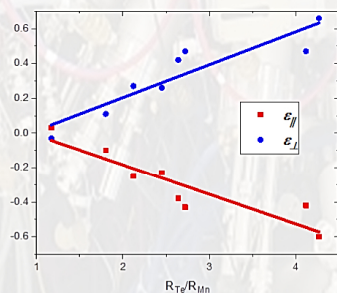
### AFM



### RSM



- $\text{Sn}_{1-x}\text{Mn}_x\text{Te}$  films,  $x_{\text{Mn}} = 0 - 0.07$ , 20-50 nm thickness
- RHEED and AFM revealed drastic increase of surface roughness when  $R_{\text{Te}}/R_{\text{Mn}} > 2$
- From RSMs we found that excess of Te induces a tetragonal distortion of the crystal structure, in-plane compressive strains up to  $-0.6\%$  introduced
- Systematic reduction of lattice constant with Mn doping was also observed



Lattice parameters, elastic strains of  $\text{Sn}_{1-x}\text{Mn}_x\text{Te}$  epilayers determined from asymmetric RSMs and their carrier concentration as a function of Te/Mn evaporation rate ratio.

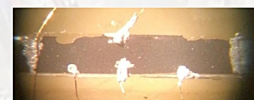
Sample	$R_{\text{Te}}/R_{\text{Mn}}$	$x_{\text{Mn}}$	% d, Å	$Q_{\text{z}}$ , Å <sup>-1</sup>	$Q_{\text{z}}$ , Å <sup>-1</sup>	$a_{\text{  }}$ , Å	$a_{\text{  }}$ , Å	$a_{\text{  }}$ , Å	$\epsilon_{\text{  }}$ , %	$\epsilon_{\text{  }}$ , %	$p$ , cm <sup>-3</sup>
G061122a	1.17	3.5	230	2.8159258	5.1761223	6.311	6.308	6.309	0.03	-0.03	1.2e+20
G091322a	1.8	4.5	500	2.821443	6.896322	6.299	6.312	6.305	-0.10	0.11	
G073022a	2.12	3.5	500	2.8234415	6.880176	6.294	6.327	6.310	-0.25	0.27	2.2e+20
G073122b	2.45	3.5	335	2.823216	6.881234	6.295	6.326	6.310	-0.23	0.26	5.8e+20
G080522a	2.64	3.7	200	2.827562	6.8710605	6.285	6.335	6.309	-0.38	0.42	5.5e+20
G080322b	2.72	3.4	300	2.828452	6.866116	6.283	6.340	6.310	-0.43	0.47	
G110422B	4.12	7.2	411	2.8359126	6.88461	6.267	6.323	6.293	-0.42	0.47	
G112322A	4.27	6.7	400	2.8397523	6.868955	6.258	6.337	6.296	-0.60	0.66	

## Summary of the results

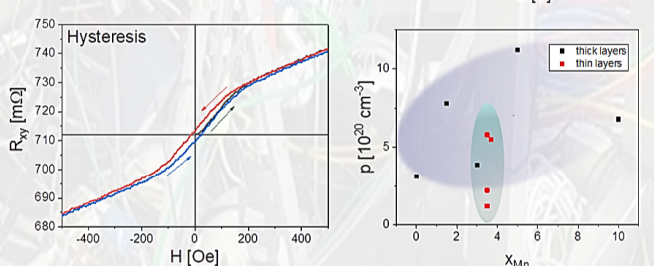
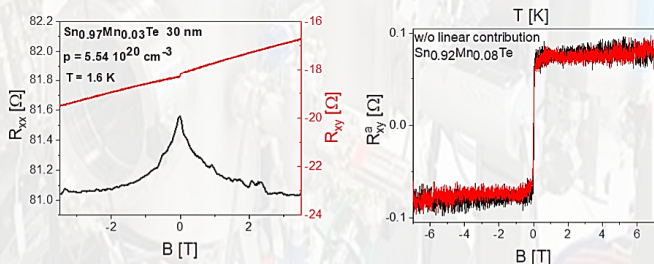
- ✓ High quality thin epilayers of FM TCI  $\text{Sn}_{1-x}\text{Mn}_x\text{Te}$  ( $x_{\text{Mn}} = 0 - 0.07$ ) were successfully prepared on  $\text{BaF}_2$  (111) substrates by MBE.
- ✓ The films with smooth surface of 20 -100 nm thickness, were grown by a two-step method involving initial low-temperature deposition followed by high-temperature annealing.
- ✓ This strain can be tuned by varying the Te content, which potentially might affect ferroelectric properties  $\text{Sn}_{1-x}\text{Mn}_x\text{Te}$ .
- ✓ Transport investigations revealed ferromagnetism in obtained samples.
- ✓ The obtained results pave the way for application this material in low temperature spintronic applications.

## Transport Characterization

- Critical behavior  $R_{\text{xx}}(T)$  at low temperatures, close to paramagnet - ferromagnet transition
- Addition of Te increases hole concentration and decreases mobility due to presence of disorder
- AHE, negative MR, WL and hysteresis are observed in Mn-doped samples as evidence of ferromagnetism
- All the samples demonstrate low coercivity of several Oe
- High field linear slope was subtracted from Hall curve to obtain AHE contribution



Silver paste was used for contacts



## Acknowledgements

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